

S9	26	S6 and (pattern\$3 near5 (bitline or wordline))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/01 13:07
S10	1	("5150898").PN.	USPAT	OR	OFF	2006/02/01 13:07
S11	1	("5158898").PN.	USPAT	OR	OFF	2006/02/01 13:07
S12	828	S6 and (pattern\$3 near5 (conduct\$3 or polysilicon or line\$1 or electrode\$1))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/01 13:20
S13	288	S12 and plug	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/01 13:21
S14	249	S13 and ((remov\$3 or etch\$3 or reduc\$3 or thin\$4) near3 spacer\$1)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/01 15:34
S15	1	"6444554".PN.	USPAT; USOCR	OR	OFF	2006/02/01 13:52
S16	1	"6573168".PN.	USPAT; USOCR	OR	OFF	2006/02/01 13:54
S17	1	"6649510".PN.	USPAT; USOCR	OR	OFF	2006/02/01 13:56
S18	1	"5565376".PN.	USPAT; USOCR	OR	OFF	2006/02/01 14:02
S19	1	"6146940".PN.	USPAT; USOCR	OR	OFF	2006/02/01 14:02
S20	1	"6239011".PN.	USPAT; USOCR	OR	OFF	2006/02/01 14:03
S21	1	"6524964".PN.	USPAT; USOCR	OR	OFF	2006/02/01 14:05
S22	1	"20030003756".PN.	US-PGPUB	OR	OFF	2006/02/01 14:06

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L7	1	("20010054764").PN.	US-PGPUB	OR	OFF	2006/02/01 15:35
S1	6948	((438/587) or (438/595) or (438/596) or (438/637) or (438/638) or (438/639) or (438/640) or (438/666) or (438/668) or (438/672) or (438/674) or (438/675) or (438/926)).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/02/01 12:50
S2	2160	S1 and spacer\$1	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/01 12:50
S3	599	S2 and (remov\$3 near3 spacer\$1)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/01 12:51
S4	728	S2 and (remov\$3 near5 spacer\$1)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/01 12:51
S5	1458	S2 and ((remov\$3 or etch\$3 or reduc\$3) near5 spacer\$1)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/01 12:51
S6	1379	S2 and ((remov\$3 or etch\$3 or reduc\$3 or thin\$4) near4 spacer\$1)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/01 13:21
S7	833	S6 and (pattern\$3 near5 (conduct\$3 or polysilicon or line\$1 or electrode\$1 or bitline or wordline))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/01 13:20
S8	290	S7 and plug	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/01 13:21